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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/762,372	01/23/2004	Kiyohito Yamamoto	00862.023416	4456	
5514	7590 02/09/2009		EXAMINER		
FITZPATRICK CELLA HARPER & SCINTO 30 ROCKEFELLER PLAZA NEW YORK, NY 10112			STOCK JR,	STOCK JR, GORDON J	
			ART UNIT	PAPER NUMBER	
			2877		

DATE MAILED: 02/09/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

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	Application No.	Applicant(s)			
	10/762,372	YAMAMOTO, KIYOHITO			
Office Action Summary	Examiner	Art Unit			
	Gordon J Stock	2877			
The MAILING DATE of this communication appeariod for Reply	ppears on the cover sheet wi	th the correspondence address			
A SHORTENED STATUTORY PERIOD FOR REP THE MAILING DATE OF THIS COMMUNICATION - Extensions of time may be available under the provisions of 37 CFR 1 after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a re - If NO period for reply is specified above, the maximum statutory perio - Failure to reply within the set or extended period for reply will, by statt Any reply received by the Office later than three months after the mail earned patent term adjustment. See 37 CFR 1.704(b).	I. 1.136(a). In no event, however, may a resply within the statutory minimum of third will apply and will expire SIX (6) MON ate, cause the application to become AB	eply be timely filed y (30) days will be considered timely. THS from the mailing date of this communication. ANDONED (35 U.S.C. § 133).			
Status					
1) Responsive to communication(s) filed on 12					
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,—	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.				
closed in accordance with the practice under	r Εχ parte Quayle, 1935 C.D	. 11, 453 O.G. 213.			
Disposition of Claims					
4) ☐ Claim(s) 15-28 is/are pending in the applicat 4a) Of the above claim(s) is/are withden 5) ☐ Claim(s) is/are allowed. 6) ☐ Claim(s) 15,17-22 and 24-28 is/are rejected. 7) ☐ Claim(s) 16 and 23 is/are objected to. 8) ☐ Claim(s) are subject to restriction and	rawn from consideration.				
Application Papers		,			
9) ☐ The specification is objected to by the Exami 10) ☑ The drawing(s) filed on 12 November 2004 is Applicant may not request that any objection to the Replacement drawing sheet(s) including the correction. 11) ☐ The oath or declaration is objected to by the	s/are: a)⊠ accepted or b)☐ ne drawing(s) be held in abeyar ection is required if the drawing	nce. See 37 CFR 1.85(a). (s) is objected to. See 37 CFR 1.121(d).			
Priority under 35 U.S.C. § 119					
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority docume 2. Certified copies of the priority docume 3. Copies of the certified copies of the priority docume application from the International Bure * See the attached detailed Office action for a life.	ents have been received. ents have been received in A riority documents have been eau (PCT Rule 17.2(a)).	pplication No received in this National Stage			
Attachment(s) 1) Notice of References Cited (PTO-892)	4) ☐ Interview 9	Summary (PTO-413)			
 2) Notice of Preferences Great (170-032) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/0 Paper No(s)/Mail Date 	Paper No(s)/Mail Date nformal Patent Application (PTO-152)			

DETAILED ACTION

Claim Rejections - 35 USC § 103

- 1. The text of those sections of Title 35, U.S. Code not included in this action can be found in a prior Office action.
- 2. Claims 15, 17-22, 24-28 are rejected under 35 U.S.C. 103(a) as being unpatentable over EP 0 989 596 A1 to Shiraishi in view of Holcman et al. (6,544,805)—previously cited.

As for claims 15 and 22, Shiraishi in a method of substrate exposure discloses the following: a first alignment system having a first stage and a first image sensing unit to detect a position of a notch-shaped mark on the substrate on said first stage using said first image sensing unit (Fig. 4: stage of 22; 30-32); a transfer system to transfer the substrate from said first stage onto a second stage (Fig. 4: 21); a second alignment system to detect a position of a second mark, alignment mark, on the substrate to align the substrate based on the detection obtained using said second image sensing unit (Fig. 4: 19; paragraph 0037) having a second stage (Fig. 4: 16); wherein the second mark is positioned within a view of said second image sensing unit (paragraph 0043).

As for having a higher magnification for the second image-sensing unit than the first,

Shiraishi is silent. However, Holcman in a method for determining orientation of a wafer

teaches that coarse alignment is used with lower magnification than fine alignment (col. 7, lines

1-5). Therefore, it would be obvious to one of ordinary skill in the art at the time the invention

was made that the second image sensing unit has a higher magnification in order to view the

smaller alignment mark in fine alignment and the first image sensing unit has a lower

magnification in order to view a larger notch mark in a coarser prealignment.

Art Unit: 2877

As for claims 17 and 24, Shiraishi in view of Holcman disclose everything as above (see claims 15 and 22). In addition, Shiraishi discloses the first alignment system aligns the substrate based on the detection using said first imaging sensing unit (paragraph 0040).

As for claims 18 and 25, Shiraishi in view of Holcman disclose everything as above (see claims 15 and 22). In addition, Shiraishi discloses the second mark is positioned within the view by moving said second stage based on the detection of said first image sensing unit (paragraphs 0037-0038).

As for claims 19 and 26, Shiraishi in view of Holcman disclose everything as above (see claims 15 and 22). In addition, Shiraishi discloses the first alignment system detects the position of the first mark based on an outer shape of the substrate (Fig. 5).

As for claims 20 and 27, Shiraishi in view of Holcman disclose everything as above (see claims 17 and 24). In addition, Shiriashi discloses driving said first stage to bring the first mark to a reference position (paragraph 0042).

As for claims 21 and 28, Shiraishi in view of Holcman disclose everything as above (see claims 15 and 22). Shiraishi is silent concerning a member onto which an end face of the substrate is pressed. However, Examiner takes official notice that chucks are well-known in the art to press wafers in position. Therefore, it would be obvious to one of ordinary skill in the art at the time the invention was made to have a vacuum chuck in the first alignment system to hold the wafer on the prealignment stage.

Allowable Subject Matter

3. Claims 16 and 23 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

As to claims 16 and 23, the prior art of record, taken alone or in combination, fails to disclose or render obvious in an exposure apparatus and alignment method the first mark and the second are the same, in combination with the rest of the limitations of claims 16 and 23.

Response to Arguments

3. Applicant's arguments with respect to the claims have been considered but are moot in view of the new ground(s) of rejection.

Conclusion

Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

Fax/Telephone Numbers

If the applicant wishes to send a fax dealing with either a proposed amendment or a discussion with a phone interview, then the fax should:

- 1) Contain either a statement "DRAFT" or "PROPOSED AMENDMENT" on the fax cover sheet; and
 - 2) Should be unsigned by the attorney or agent.

This will ensure that it will not be entered into the case and will be forwarded to the examiner as quickly as possible.

Papers related to the application may be submitted to Group 2800 by Fax transmission. Papers should be faxed to Group 2800 via the PTO Fax machine located in Crystal Plaza 4. The form of such papers must conform to the notice published in the Official Gazette, 1096 OG 30 (November 15, 1989). The CP4 Fax Machine number is: (703) 872-9306

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Gordon J. Stock whose telephone number is (571) 272-2431.

The examiner can normally be reached on Monday-Friday, 10:00 a.m. - 6:30 p.m.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Gregory J. Toatley, Jr., can be reached at 571-272-2800 ext 77.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private Pair system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

gs February 5, 2005

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